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INTERNATIONAL STANDARD



Device embedding assembly technology – 12 11 18

Part 2-5: Guidelines – Implementation of a 3D data format for device embedded substrate

Document Preview

IEC 62878-2-5:2019

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67 000 electrotechnical terminology entries in English and French extracted from the Terms and Definitions clause of IEC publications issued since 2002. Some entries have been collected from earlier publications of IEC TC 37, 77, 86 and CISPR.



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INTERNATIONAL STANDARD



Device embedding assembly technology – 1210S

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INTERNATIONAL ELECTROTECHNICAL COMMISSION

DEVICE EMBEDDING ASSEMBLY TECHNOLOGY -

Part 2-5: Guidelines – Implementation of a 3D data format for device embedded substrate

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International Standard IEC 62878-2-5 has been prepared by IEC technical committee 91: Electronics assembly technology.

This first edition cancels and replaces IEC PAS 62878-2-5 published in 2015. This edition constitutes a technical revision.

This edition includes the following significant technical changes with respect to the previous edition:

- a) the title has been changed to "Implementation of a 3D data format for device embedded substrate" from "Requirements of design date format for device embedded substrate";
- b) the scope of this implementation has changed to not include SiPs.

The text of this International Standard is based on the following documents:

CDV	Report on voting
91/1557/CDV	91/1589/RVC

Full information on the voting for the approval of this International Standard can be found in the report on voting indicated in the above table.

This document has been drafted in accordance with the ISO/IEC Directives, Part 2.

A list of all parts in the IEC 62878 series, published under the general title *Device embedding assembly technology*, can be found on the IEC website.

Future standards in this series will carry the new general title as cited above. Titles of existing standards in this series will be updated at the time of the next edition.

The committee has decided that the contents of this document will remain unchanged until the stability date indicated on the IEC website under "http://webstore.iec.ch" in the data related to the specific document. At this date, the document will be

- reconfirmed,
- withdrawn,
- replaced by a revised edition, or Standards
- amended.

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DEVICE EMBEDDING ASSEMBLY TECHNOLOGY -

Part 2-5: Guidelines – Implementation of a 3D data format for device embedded substrate

1 Scope

This part of IEC 62878 specifies requirements based on XML schema that represents a design data format for device embedded substrate, which is a board comprising embedded active and passive devices whose electrical connections are made by means of a via, electroplating, conductive paste or printing of conductive material.

This data format is to be used for simulation (e.g. stress, thermal, EMC), tooling, manufacturing, assembly, and inspection requirements. Furthermore, the data format is used for transferring information among printed board designers, printed board simulation engineer, manufacturers, and assemblers.

This part of IEC 62878 applies to substrates using organic material. It neither applies to the re-distribution layer (RDL) nor to the electronic modules defined as M-type business model in IEC 62421.

2 Normative references / standards.iteh.ai)

There are no normative references in this document.

3 Terms and definitions

For the purposes of this document, the following terms and definitions apply. $^{1/lec-62878-2-5-2019}$

ISO and IEC maintain terminological databases for use in standardization at the following addresses:

- IEC Electropedia: available at http://www.electropedia.org/
- ISO Online browsing platform: available at http://www.iso.org/obp

3.1

artwork information

information that shows a SiP not included in net and figure data in board (symbol mark, inside of SiP, mould, spacer, remarks, etc.)

3.2

board information

total information of a device-embedded substrate, including embedded devices

3.3

chip stack

package of semiconductor chips stacked vertically

3.4

clearance

area around a through-hole where there is no conductor to prevent electrical connection between a large conductor area, such as that of a power supply or a ground and a plated through-hole

3.5

computer-aided manufacturing

CAM

interactive use of computer systems, programs, and procedures in various phases of a manufacturing process wherein the decision-making activity rests with the human operator and a computer provides the data manipulation functions

3.6

computer-aided design

CAD

interactive use of computer systems, programs, and procedures in the design process wherein the decision-making activity rests with the human operator and a computer provides the data manipulation function

3.7 DXF

data format for AutoCAD

Note 1 to entry: AutoCAD is the trade name of a product supplied by Autodesk®. This information is given for the convenience of users of this document and does not constitute an endorsement by IEC of the product named. Equivalent products may be used if they can be shown to lead to the same results.

Note 2 to entry: It generally means a type of data format to draw figures using CAD board data.

3.8

design document

documentation of information necessary in circuit board design

3.9

device arrangement information

information that includes the position, the shape and attributes of the embedding device included in the net information

3.10

device embedded substrate advice/02/58

substrate in which an active device(s) (semiconductor device) and/or passive device(s) (e.g. resistor, capacitor) is formed using thick-film technology or by embedding it within the substrate

3.11

FLIP chip

FC

leadless monolithic circuit element structure that electrically and mechanically interconnects to a printed board by conductive bumps

3.12

Gerber

type of data format that consists of aperture selection and operation commands and dimensions in X- and Y-coordinates

Note 1 to entry: The data is generally used to direct a photo-plotter in generating photo-plotted artwork.

Note 2 to entry: Gerber is the trade name of a product supplied by Ucamco. This information is given for the convenience of users of this document and does not constitute an endorsement by IEC of the product named. Equivalent products may be used if they can be shown to lead to the same results.

3.13

interposer

material placed between two surfaces giving electrical insulation, redistribution of electrical connections, mechanical strength and/or controlled mechanical and thermal separation between the two surfaces

Note 1 to entry: An interposer may be used as a means for redistributing electrical connections and/or allowing for different thermal expansions between adjacent surfaces.

3.14

land

pad

portion of a conductive pattern usually used for the connection and/or attachment of components

3.15

land definition

maintainance of a shape of specific land, pad, solder resist and others

3.16

layer definition

combination of physical information of shape and construction and logic information giving design and production units

3.17

layer map

map showing the relation between devices and the board, the devices being arranged on the board

3.18

library

database of design information, based on a design document, to be used in board CAD

3.19

logical layer

layer that can be arbitrarily formed in the event that it is difficult to physically express a layer in a design

Note 1 to entry: It is possible to relate it to a physical layer.

Note 2 to entry: It is different from the layers in a multi-layer substrate. 8fe5-2f3058383e71/iec-62878-2-5-2019

3.20

micro-electro-mechanical system

MEMS

system integrating micro-machine, mechanical elements, sensor, actuator, and electronic circuit into one module

3.21

net information

device pin construction and wiring pattern in this PAS

3.22

package information

shapes of board and devices when they have package shape patterns in this document

3.23

PoP

package on package

single or multiple package(s) mounted on a package of a single chip or multiple chips as single package

3.24

physical layer

layer consisting of a physical layer construction and structure

3.25

port information

information of figures and names of external terminals of a device or a substrate with terminals

3.26

structure

total structure of a device embedded substrate and/or surface device mounted to the substrate

3.27

SiP

system in a package

multi-chip package (MCP) that performs a system function

3.28

thermal land

heat energy may leak to outside of a land/through-hole when a device is soldered on a large pattern such as power supply or ground. A cut is often made around such a soldering point to prevent thermal dissipation

3.29

through silicon via

TSV

hole made in a silicon chip and filled with metal to electrically connect upper and lower side of the chip for 3D stacking package

3.30

via definition

via that is used as an interlayer connection, but in which there is no intention to insert a component lead or other reinforcing material

3.31

virtual layer

name of the layer connecting conductor layers when a device is embedded

Note 1 to entry: It corresponds to the connection point of a device terminal specified in IEC TS 62678-2-3.

3.32

wire bonding

WB

micro-bonding between a die and base material, lead frame, etc.

4 Data definition

4.1 Flow chart design of device embedded substrate

Figure 1 shows the design flow of a device embedded substrate. The design data can be directly sent to a board manufacturing system using this format, or can be converted to CAM data and then be used in production. The data contain 3D information of coordinates and shapes of devices used. It is possible to check the status of device embedding in a board, and also make it a common knowledge in production know-how of a production line.

This file format describes the detailed 3D information of the following electronic circuit boards, including device embedded substrate and SiP (system in package), and makes it possible to use necessary information from the stage of design to the fabrication of products.

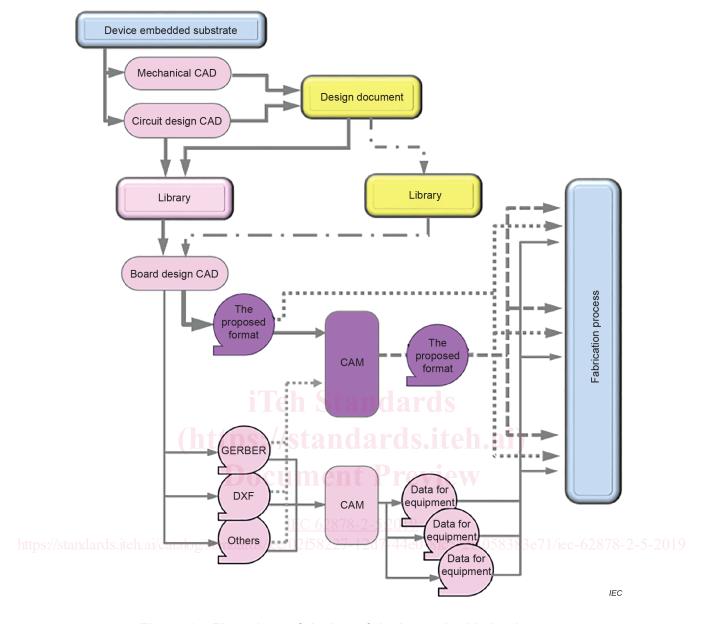
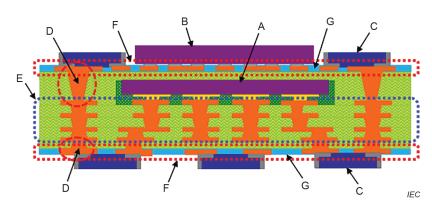


Figure 1 – Flow chart of design of device embedded substrate

4.2 Applicable range

4.2.1 Product

It is possible to maintain the following design information of a device embedded substrate as shown in Figure 2.



- A Embedded active device
- B Surface mounted active device
- C Surface mounted passive device
- D Layer connecting via

- E Inner pattern
- F Surface pattern
- G Solder resist

Figure 2 - General structure of device embedded substrate

4.2.2 Process

The format describes maintained and available information of each stage in production as described in Table 1:

- 1) design, (https://standards.iteh.a)
- 2) simulation,
- 3) substrate fabrication, DOCUMENT FreVIEW
- 4) device embedding,
- 5) test. IEC 62878-2-5:2019

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